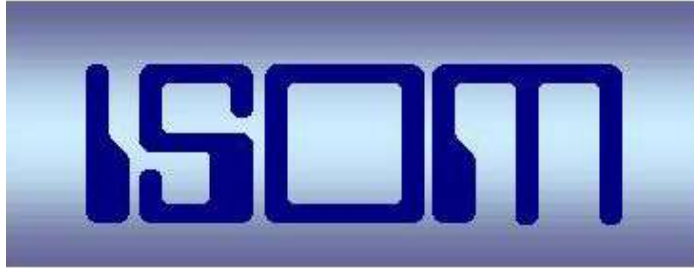




POLITÉCNICA



Deep Level Analysis of Homoepitaxial ZnO Doped with N

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Introduction

What blocks the full development of oxides? p-type doping

- High intrinsic carrier concentration (n-type)
- Efforts to reduce this effect:
 - Homoepitaxy¹
 - Non-polar orientations
- Similar samples exhibit residual doping as low as $\sim 10^{14} \text{ cm}^{-3}$ (2)

The path to p-type doping

- Many dopants proposed
- N is a promising candidate
 - Simple N_O is a deep level
 - Complex levels have shallower energies
- N-related levels observed near the VB by many groups
 - Energies between 130 meV and 160 meV from VBM

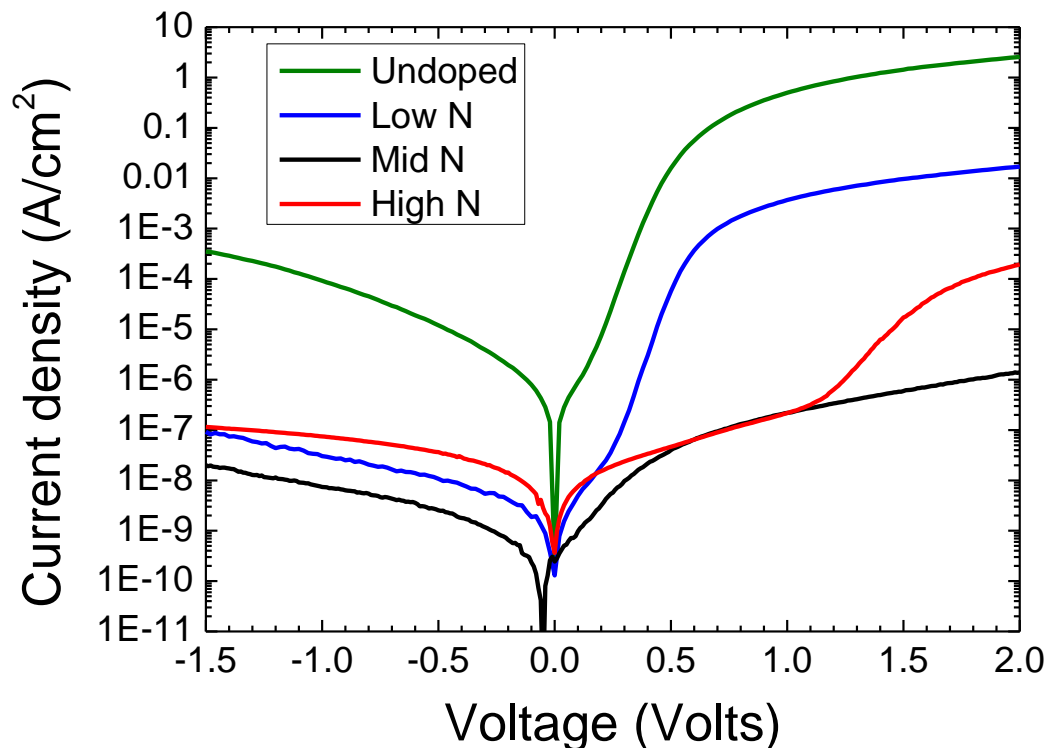
¹Lautenschlaeger et al., *J.Cryst.Growth* 312, (2011)

²Tainoff et al., *Appl.Phys.Lett.* 98, 131915, (2011)

Sample description

Sample	Ideality factor	Barrier height (eV)	R_s ($\Omega \cdot \text{cm}^2$)	R_c ($\Omega \cdot \text{cm}^2$)	Thickness (μm)
Undoped	1.3	1.0	0.4	$9.5 \cdot 10^7$	1.5
Low N	1.2	1.2	61.5	$4.2 \cdot 10^9$	1.3
Mid N	3.3	1.2	$4.8 \cdot 10^5$	$1.1 \cdot 10^{10}$	1.5
High N	-	-	-	-	1.8

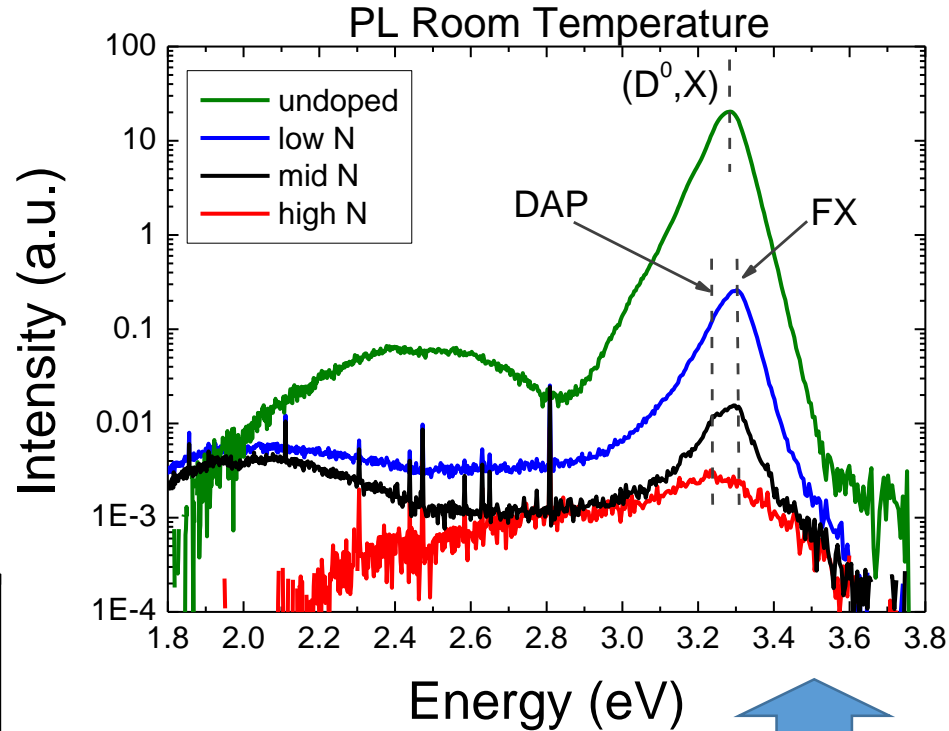
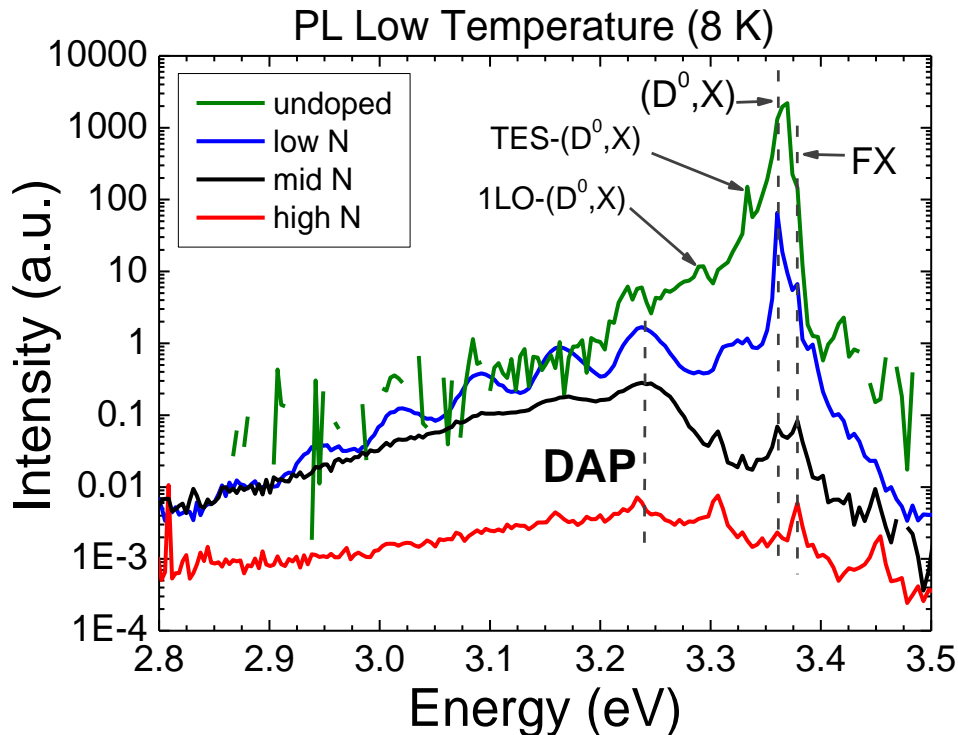
- Grown by MBE on m-plane ZnO
- Doped with N¹
- Semitransparent 100 Å-thick Au Schottky diodes
- Surface treated with H₂O₂



¹Tainoff et al., *Appl.Phys.Lett.* 98, 131915, (2011)

Photoluminescence (PL)

- DAP at low T observed, similar to previous results¹
- $[N] \sim 10^{19} \text{ cm}^{-3}$ in mid N sample¹



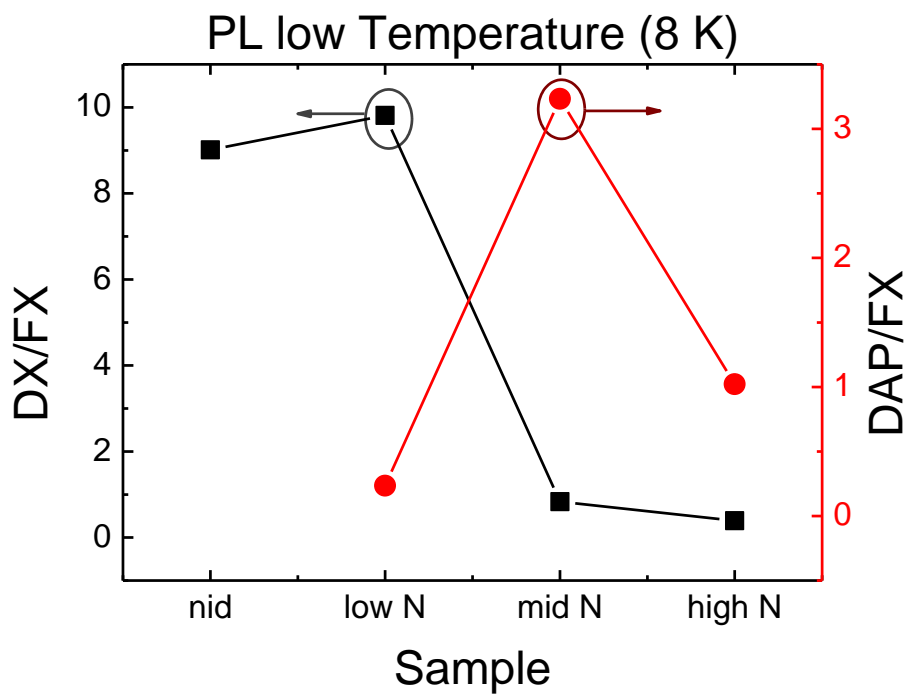
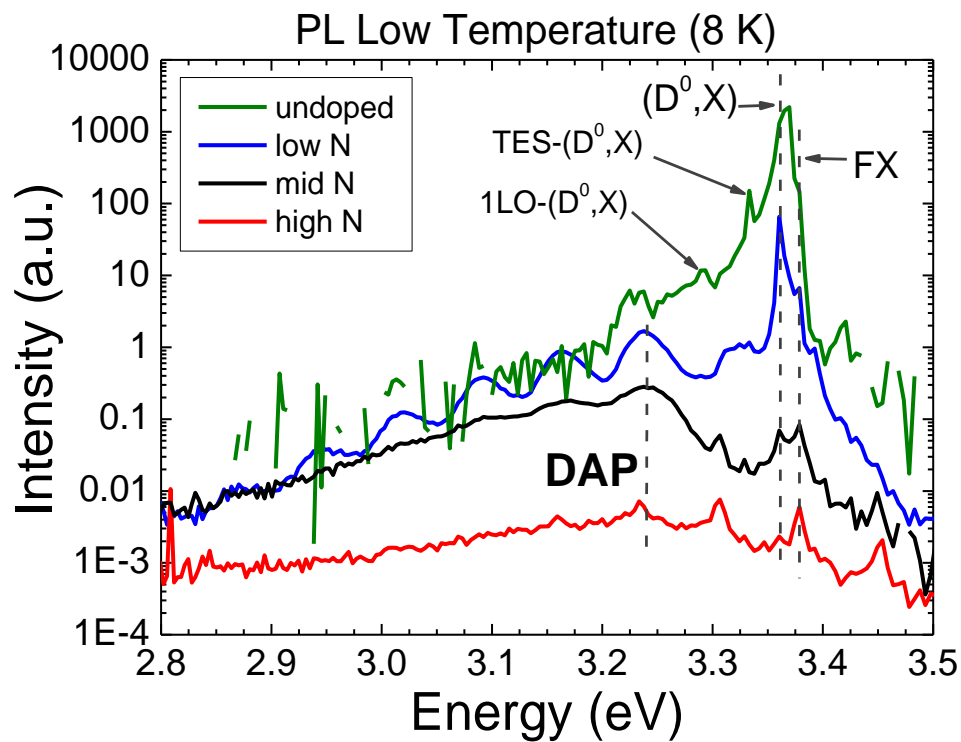
RT-DAP at 0.12 eV below $E_g = 3.37 \text{ eV}$

High crystalline quality: FX, D⁰X, TES- D⁰X, LO- D⁰X observed

¹Tainoff et al., *Appl.Phys.Lett.* 98, 131915, (2011)
²H. Morkoç, U. Özgür, *Zinc Oxide Fundamentals, Materials and Device Technology*, Wiley (2009)

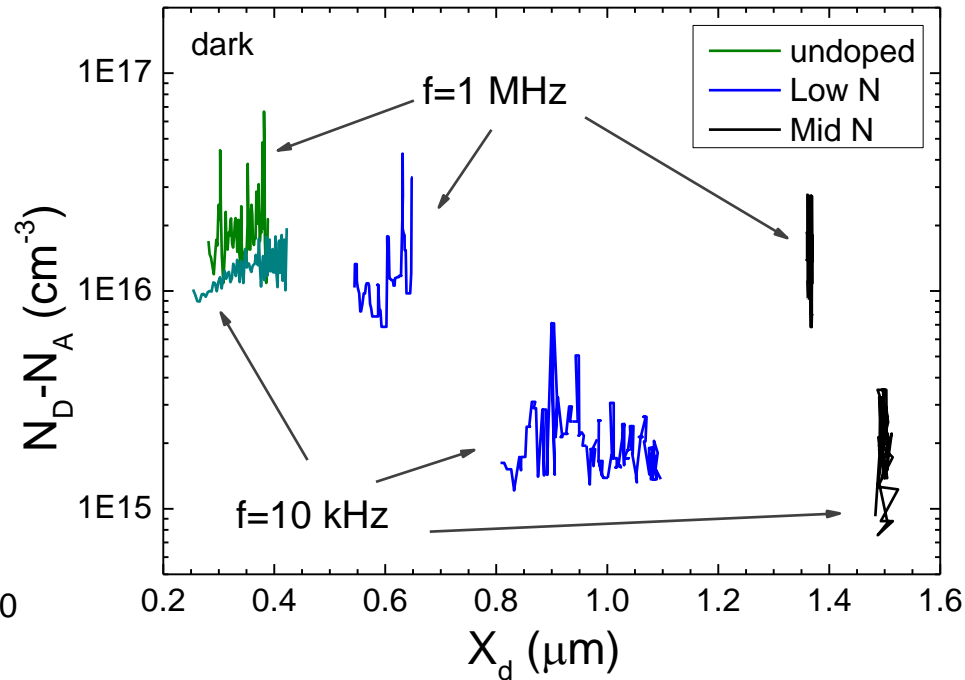
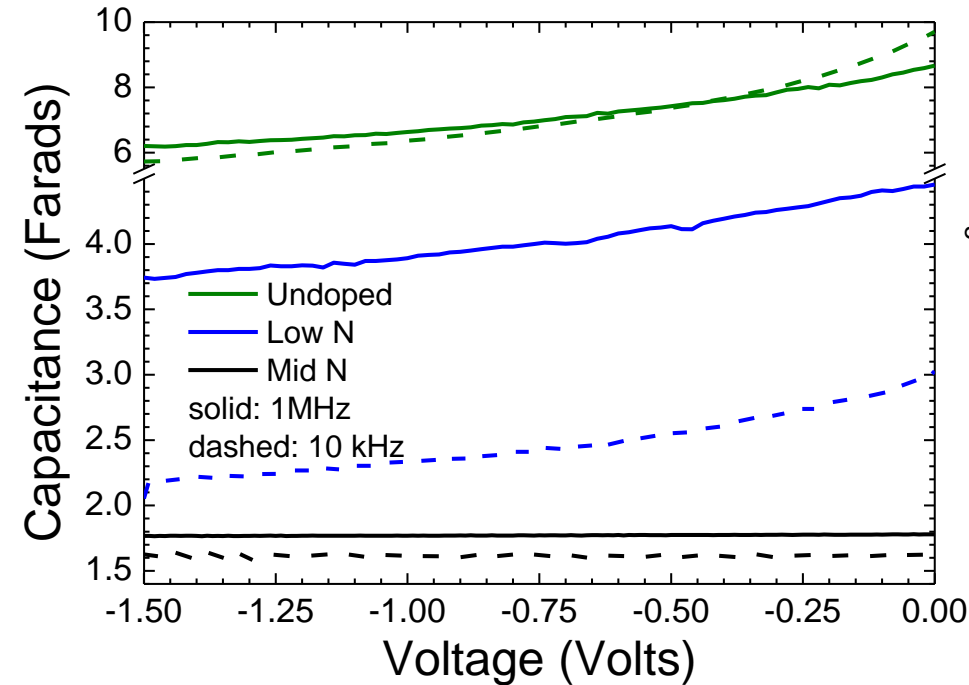
PL analysis

- Donor-bound exciton (D^0, X) decays with N concentration and FX remains \rightarrow N incorporation reduces the donor concentration ?
- Donor-acceptor-pair (DAP) appears with N and dominates \rightarrow Acceptors incorporated



DAP dominates for increasing N concentration

Capacitance-Voltage (CV)

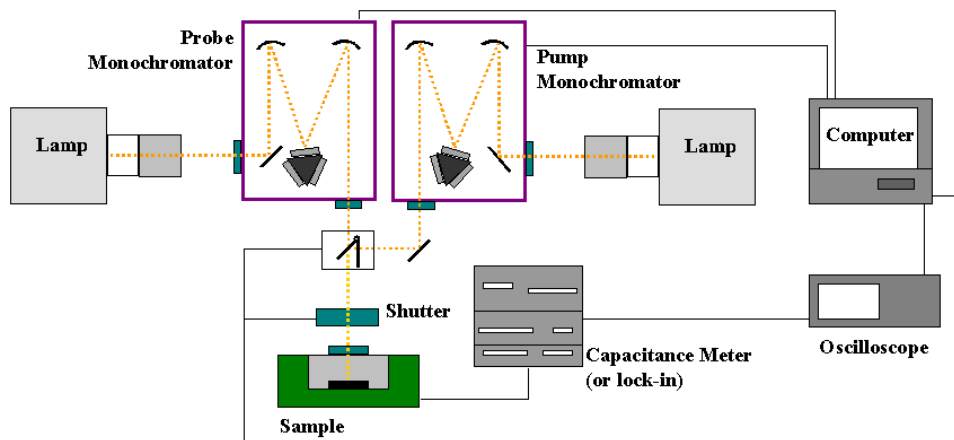
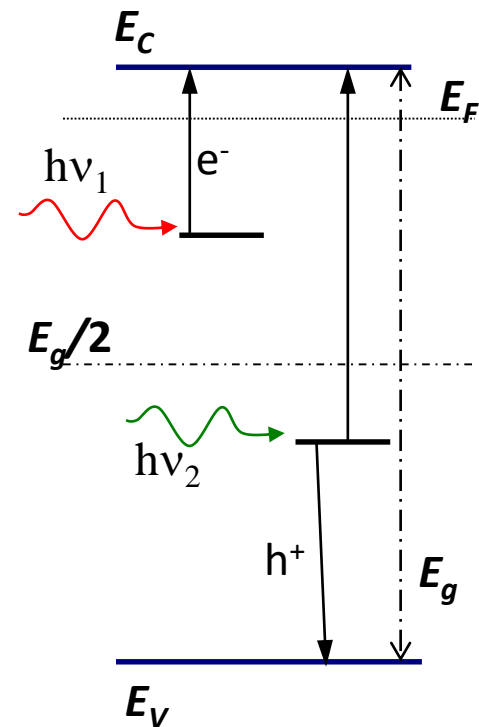
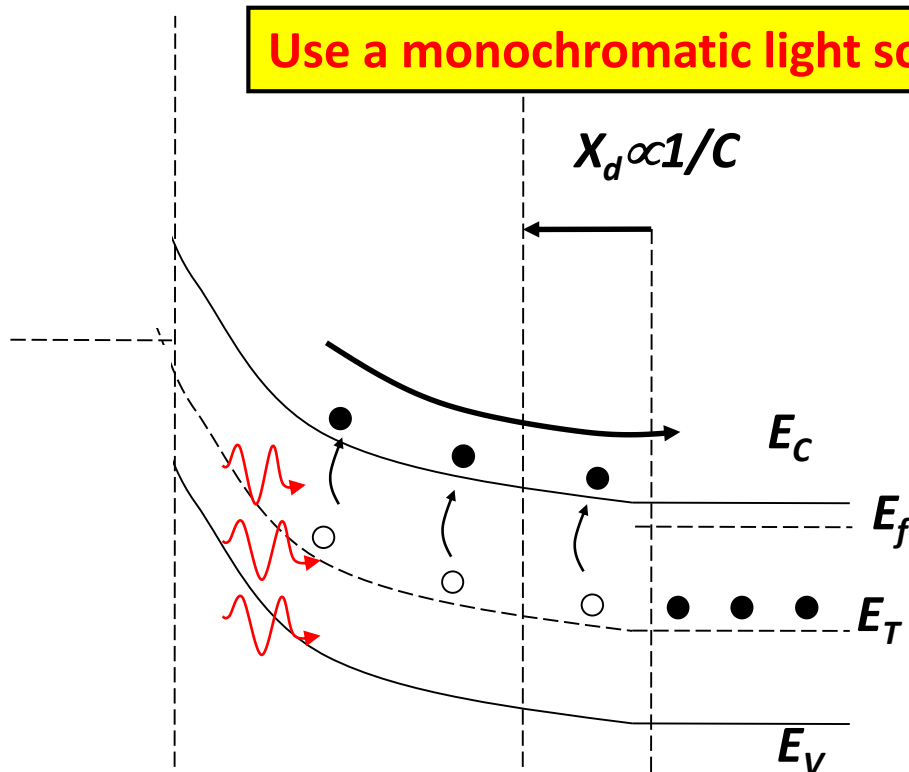


- Measurements done in the dark
- High N sample completely depleted \rightarrow Not measurable

- Mid N sample heavily compensated in the dark
- N-type even under illumination
 - \triangleright Tested using lighted-CV (not shown)
- Change in CV with frequency
 - \triangleright Low efficiency of the compensating agent

Deep level optical spectroscopy (DLOS)

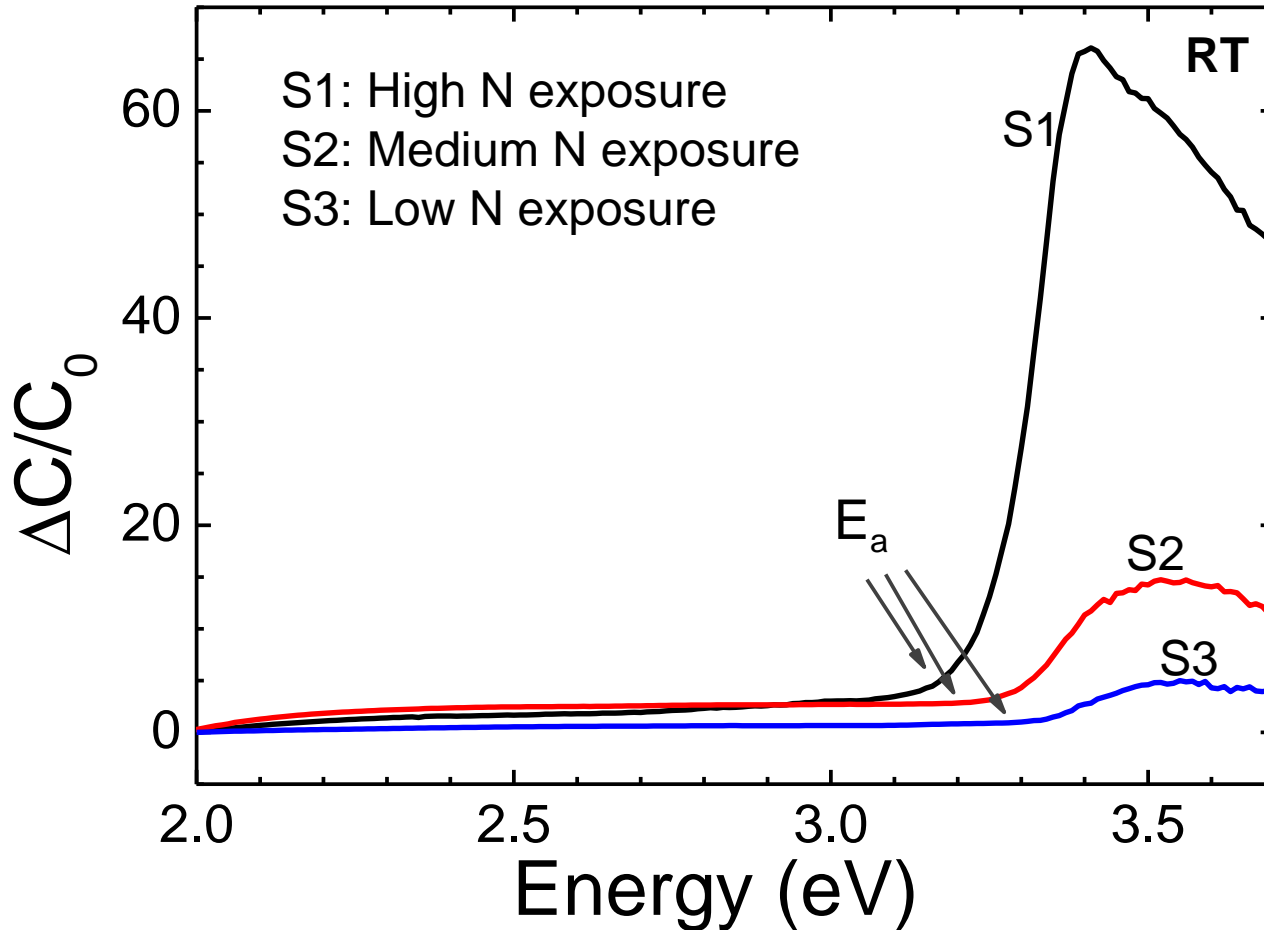
Use a monochromatic light source to scan throughout the bandgap



- Onset in ΔC gives deep level energy
- Concentration depends on ΔC magnitude
- $N_T = 2 \times (N_D^+ - N_A^-) \times \frac{\Delta C}{C_0} \quad (cm^{-3})$

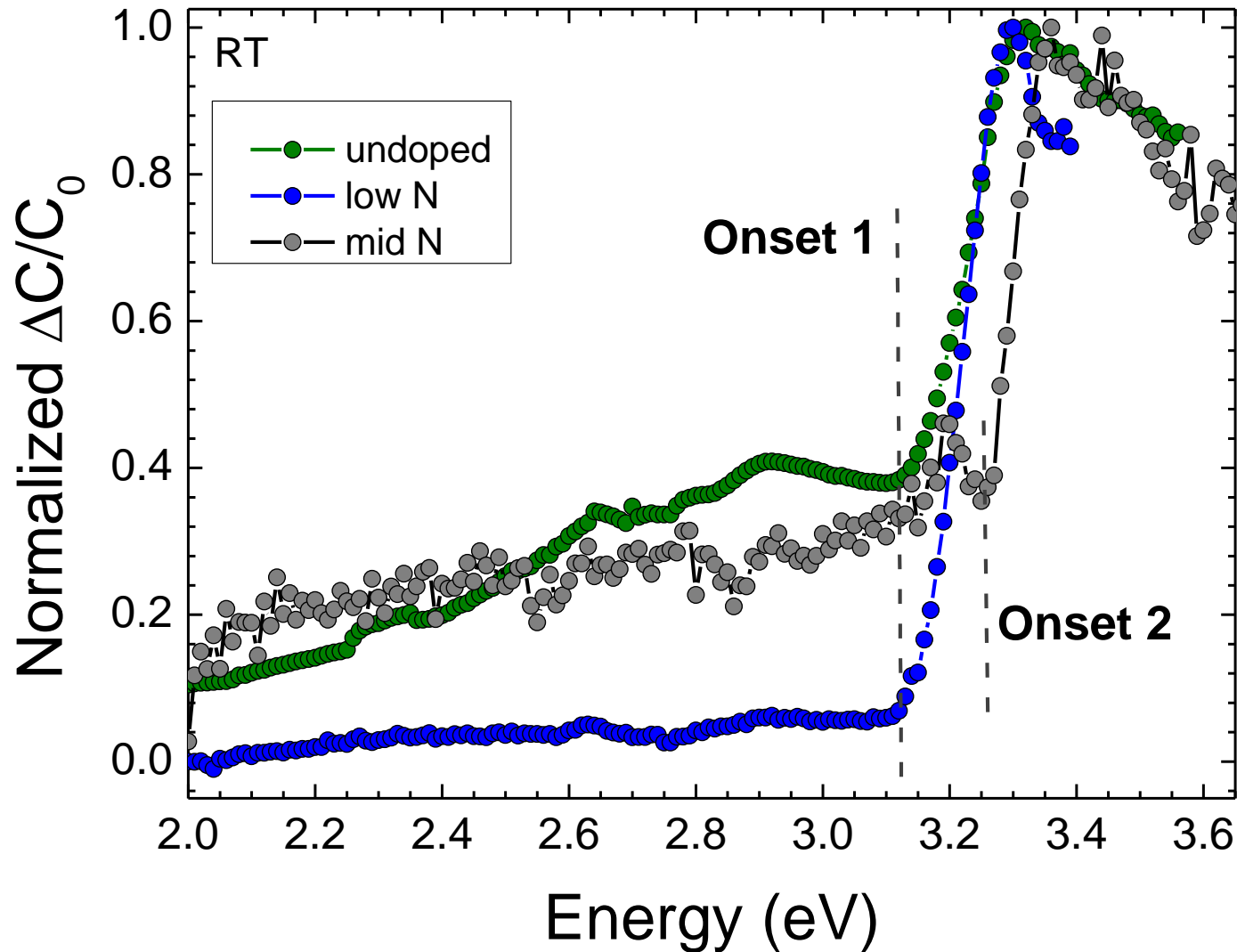
DLOS – Example spectra

ZnMgO:N grown by RPE-MOCVD at SU



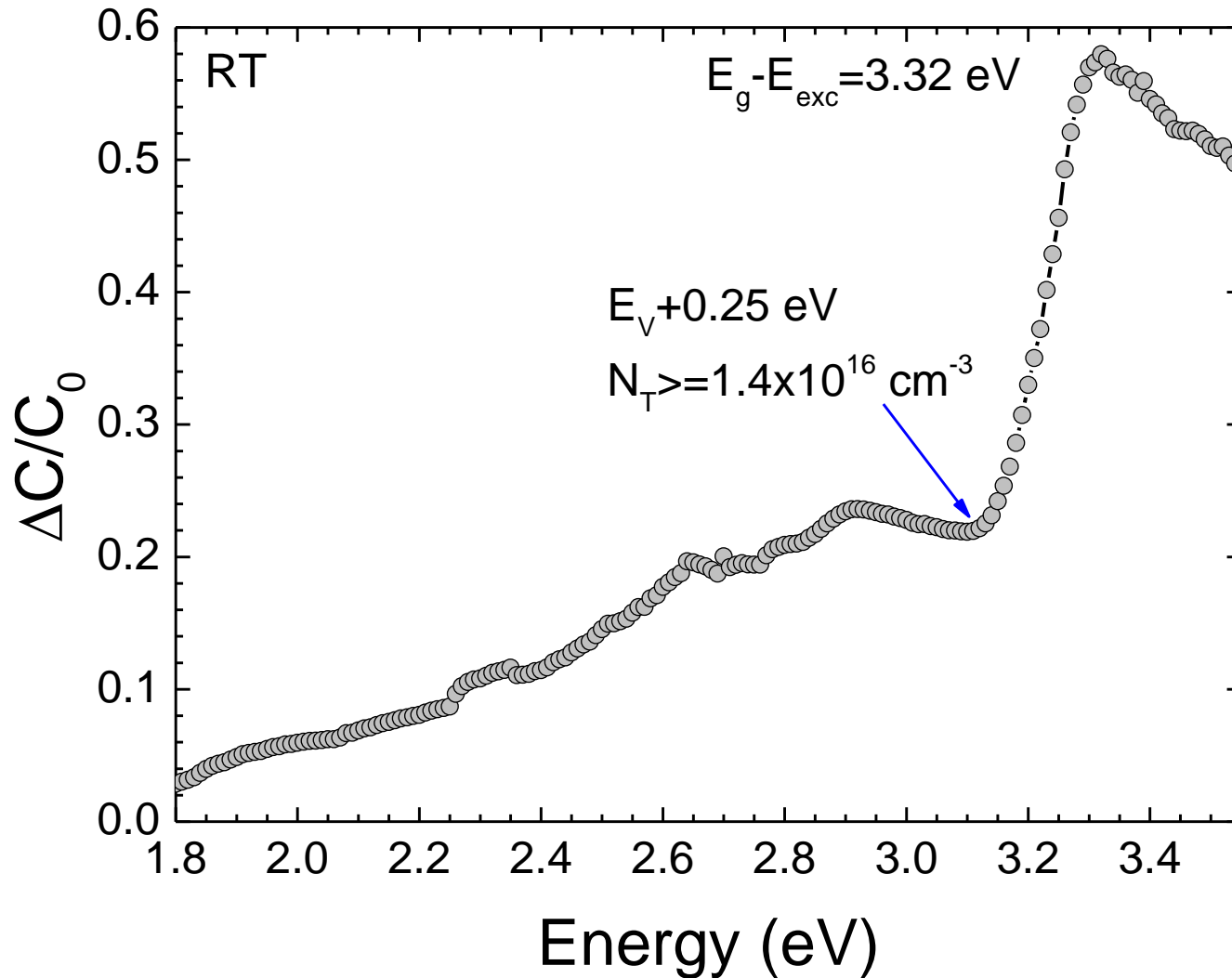
- Levels are referenced to VB in n-type material
- E_a is calculated subtracting the onset to the gap energy (E_g)
- Capacitance rises till gap or excitonic absorption \rightarrow Q-factor degradation

DLOS for all samples (1MHz)



- Undoped and low N samples very similar near bandgap \rightarrow Different in mid-gap
- Mid N sample changes deep level distribution

Undoped ZnO

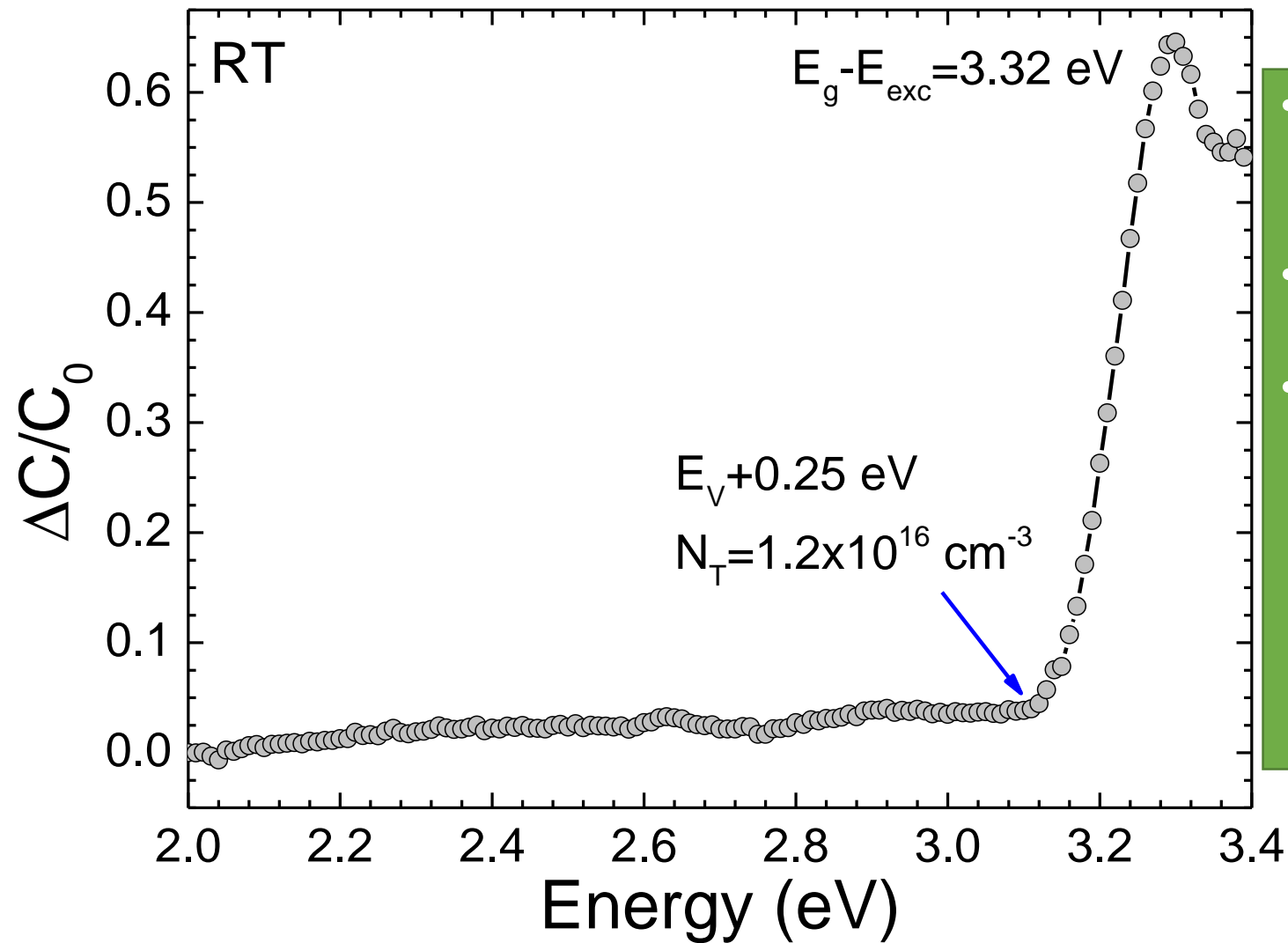


- Dominant level at $E_V + 0.25 \text{ eV}$
- Capacitance degrades when resonant with the exciton \rightarrow Increase in conduction¹
- Concentration is a lower bound

Sample very sensitive to lamp features and filter changes
 \rightarrow Difficult to determine traps deep in the bandgap

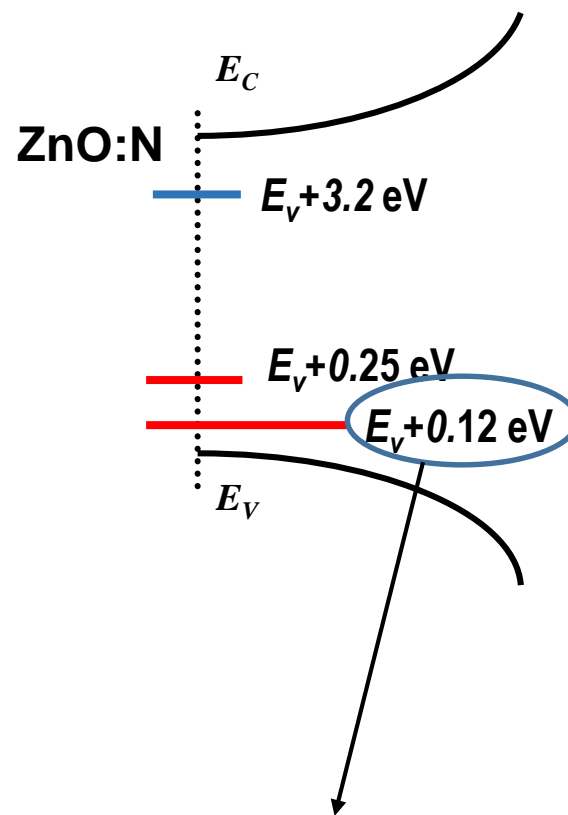
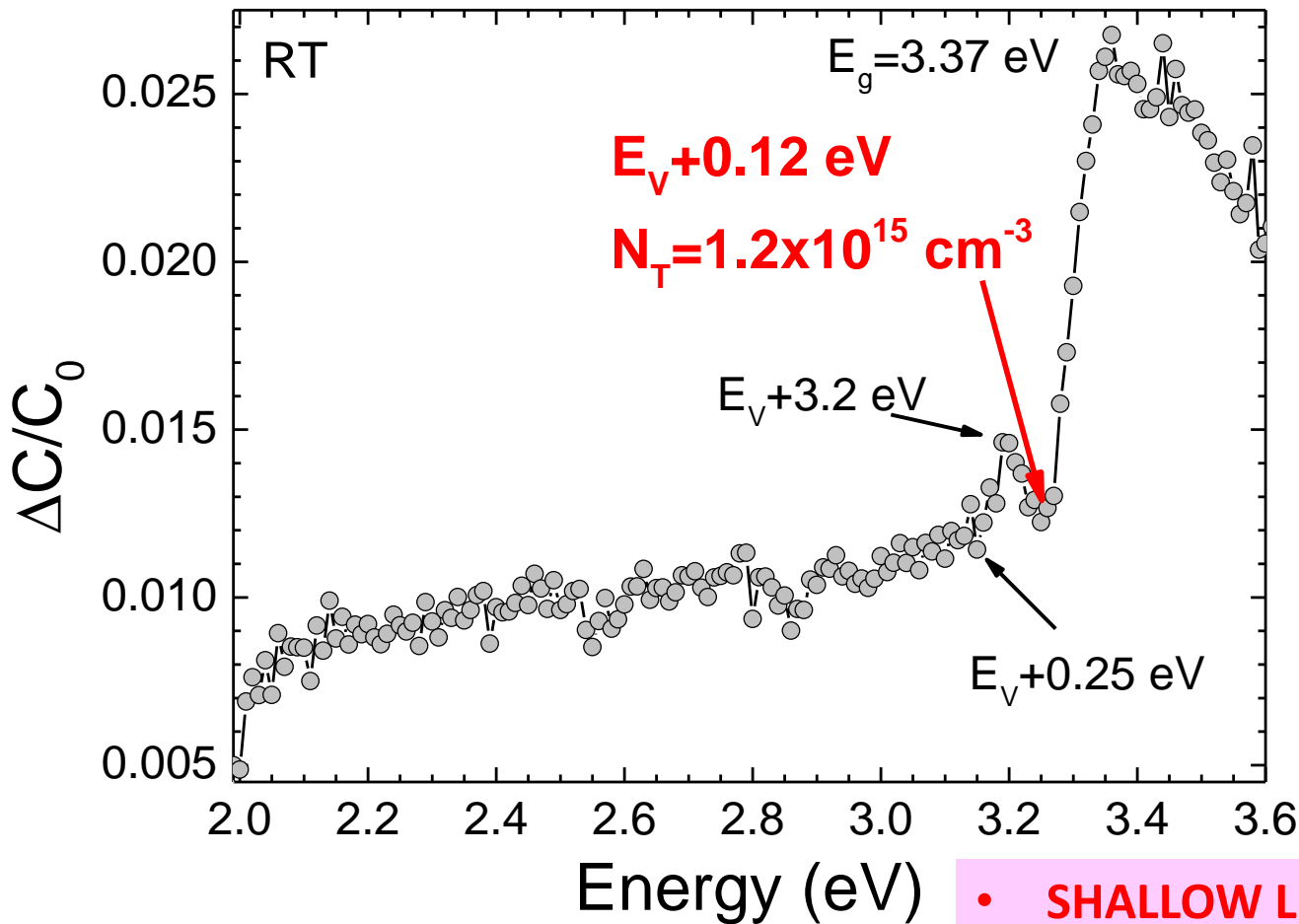
¹Shown in a later slide

Low N ZnO



- Same level at $E_V + 0.25 \text{ eV}$ as in undoped sample
- Similar concentration
- No significant ΔC variation until high energies \rightarrow Reduction in levels deep in the band

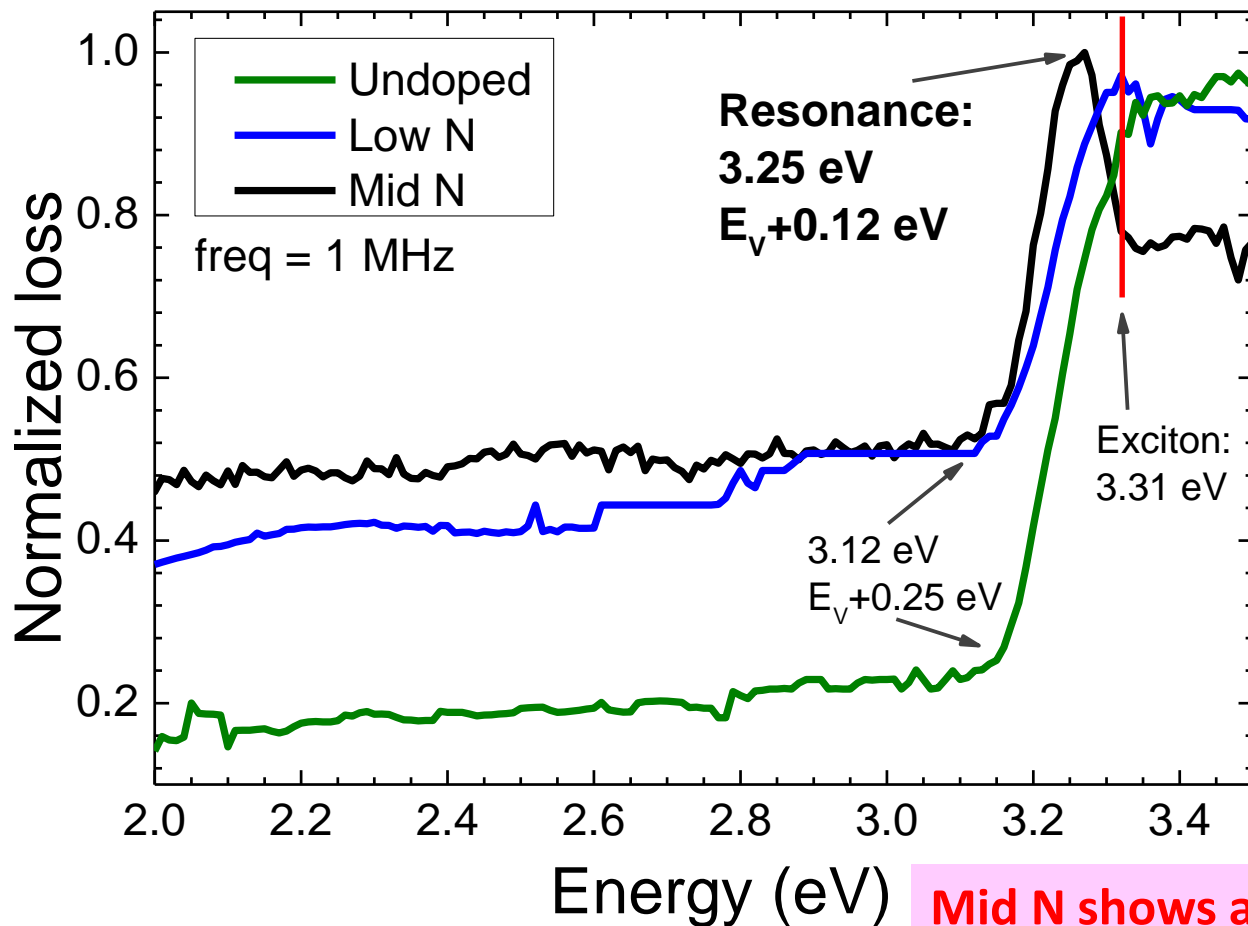
Mid N ZnO



- **SHALLOW LEVEL** introduced by N
- **Matches perfectly DAP** from RT-PL

- Level at $E_V + 0.25 \text{ eV}$ is not responsible for the capacitance change
- New donor-like level appears at $E_V + 3.2 \text{ eV}$ ($E_C - 0.17 \text{ eV}$)

Losses at 1 MHz



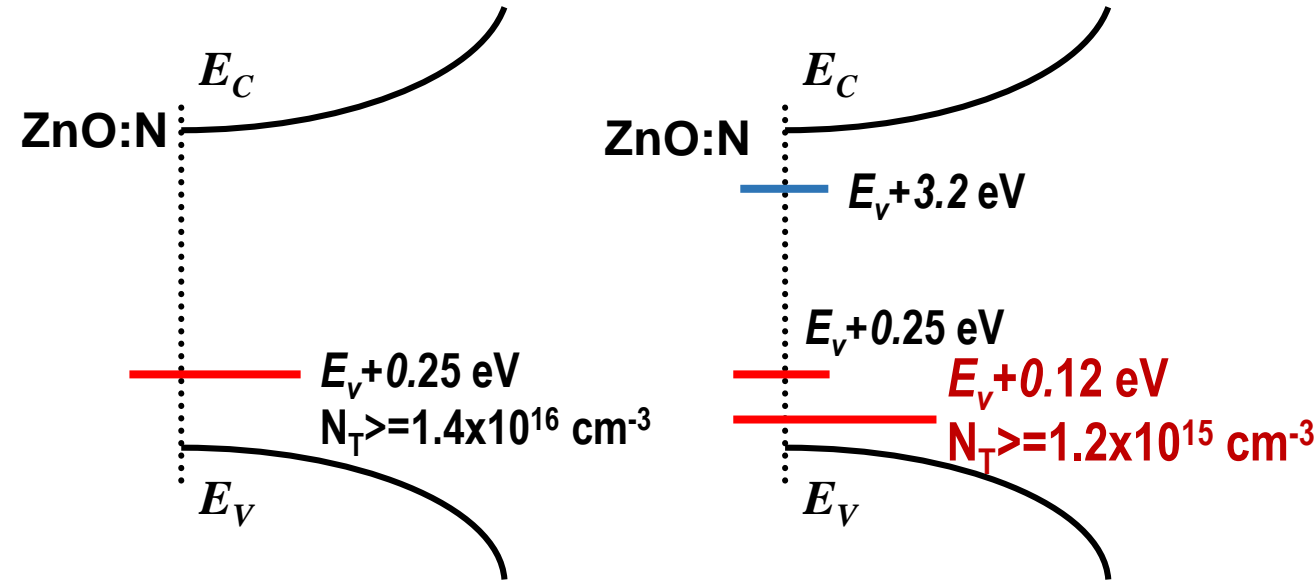
- Losses = Conductance at 1MHz
- Modulated photocurrent
- Measures free charge at high freq.

**Mid N shows a resonance at $E_V + 0.12$ eV
 → Trap being emptied: Matches $\Delta C/C$**

- All samples start rising at 3.12 eV → Modulation
- Undoped and low N samples rise up to exciton energy

Undoped and Low N

Mid N



- $E_V + 0.25$ eV present in all samples
- N-related level at $E_V + 0.12$ eV \rightarrow Agrees with report by Muret¹
- Donor-like level at $E_V + 3.2$ eV only visible with high N concentration

- N introduces an acceptor level at $E_V + 0.12$ eV ($N_T = 10^{15} \text{ cm}^{-3}$)
- $E_V + 0.12$ eV level matches well donor-acceptor-pair (DAP)

¹Muret et al., *Appl.Phys.Lett.* 101, 122104, (2012)



THANK FOR YOUR ATTENTION!!!